

Accepted Manuscript

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PII: S0040-6090(17)30520-5
DOI: doi: [10.1016/j.tsf.2017.07.026](https://doi.org/10.1016/j.tsf.2017.07.026)
Reference: TSF 36092

To appear in: *Thin Solid Films*

Received date: 9 September 2016

Revised date: 30 June 2017

Accepted date: 11 July 2017

Please cite this article as: Toru Utsunomiya, Taiki Kanzawa, Takashi Ichii, Hiroyuki Sugimura, Protective layer for cycloolefin polymer against an aromatic solvent prepared by chemical vapor deposition using cyclosiloxane as a raw molecule, *Thin Solid Films* (2017), doi: [10.1016/j.tsf.2017.07.026](https://doi.org/10.1016/j.tsf.2017.07.026)

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Protective Layer for Cycloolefin Polymer against an
Aromatic Solvent Prepared by Chemical Vapor
Deposition Using Cyclosiloxane as a Raw Molecule

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